



US00D957957S

(12) **United States Design Patent**
Cho

(10) **Patent No.:** **US D957,957 S**

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(54) **AIR QUALITY MEASURING APPARATUS**

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(**) Term: **15 Years**

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(30) **Foreign Application Priority Data**

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(52) **U.S. Cl.**
USPC **D10/52; D10/53**

(58) **Field of Classification Search**
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2001/2279; G01N 7/00; G01N 7/02;
G01N 7/04; G01N 7/06; G01N 7/08;
G01N 7/10; G01N 7/12; G01N 7/14;
G01N 7/16; G01N 7/18; G01N 7/20;
G01N 7/22; G01N 33/009; G01N
33/0075; H04B 17/23

See application file for complete search history.

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(57) **CLAIM**

I claim, the ornamental design for an air quality measuring apparatus, as shown and described.

DESCRIPTION

FIG. 1 is a perspective view of an air quality measuring apparatus, showing my new design;
FIG. 2 is a front elevation view thereof;
FIG. 3 is a rear elevation view thereof;
FIG. 4 is a left side elevation view thereof;
FIG. 5 is a right side elevation view thereof;
FIG. 6 is a top plan view thereof;
FIG. 7 is a bottom plan view thereof; and,
FIG. 8 is a reference perspective view thereof showing a configuration of use.
The broken lines in FIGS. 3 and 8 show portions of the air quality measuring apparatus which form no part of the claimed design.
The word "NAVIEN" forming a part of the disclosure is a registered trademark of Kyungdong Navien Co., Ltd.

1 Claim, 8 Drawing Sheets

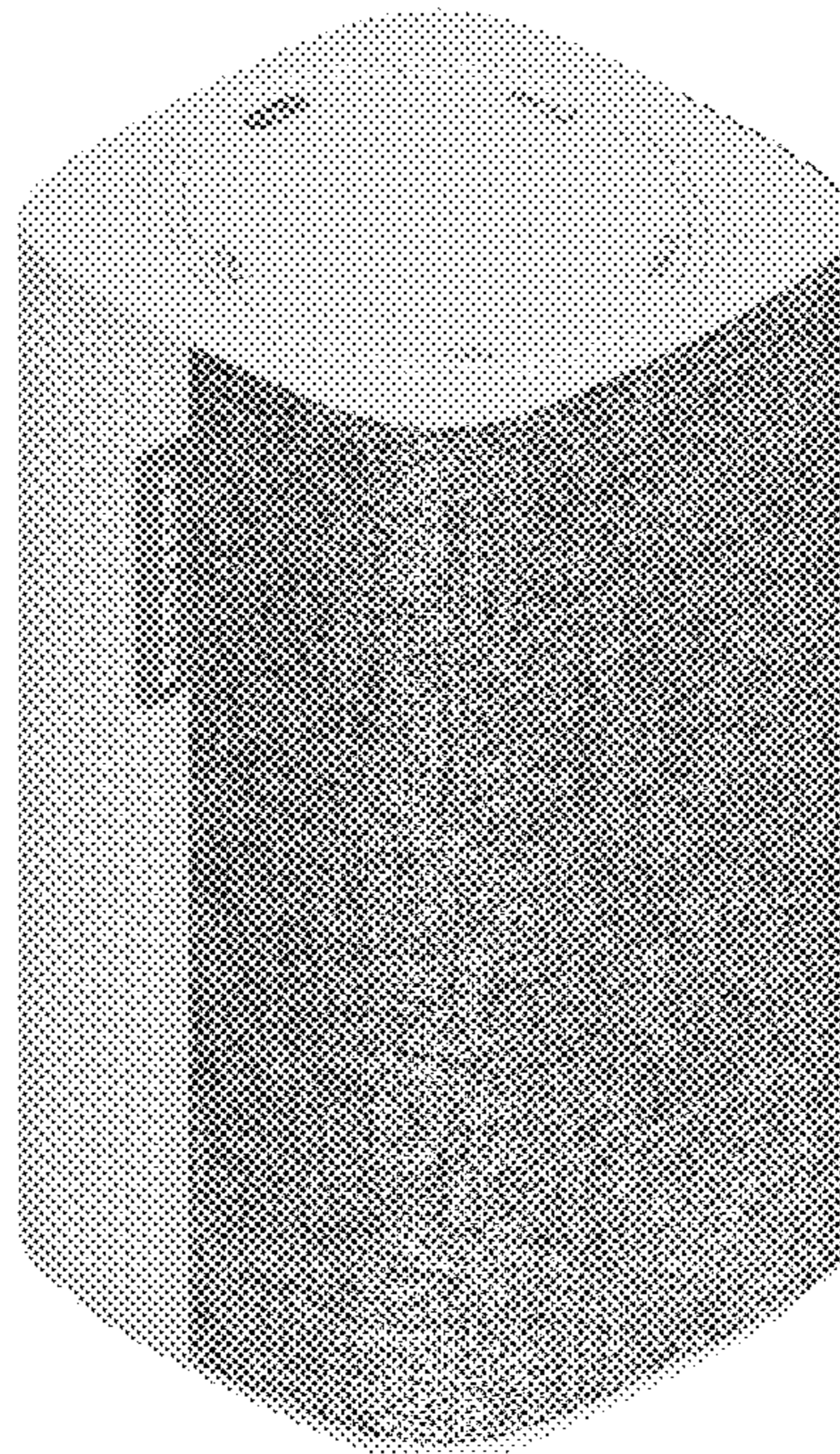


Fig 1

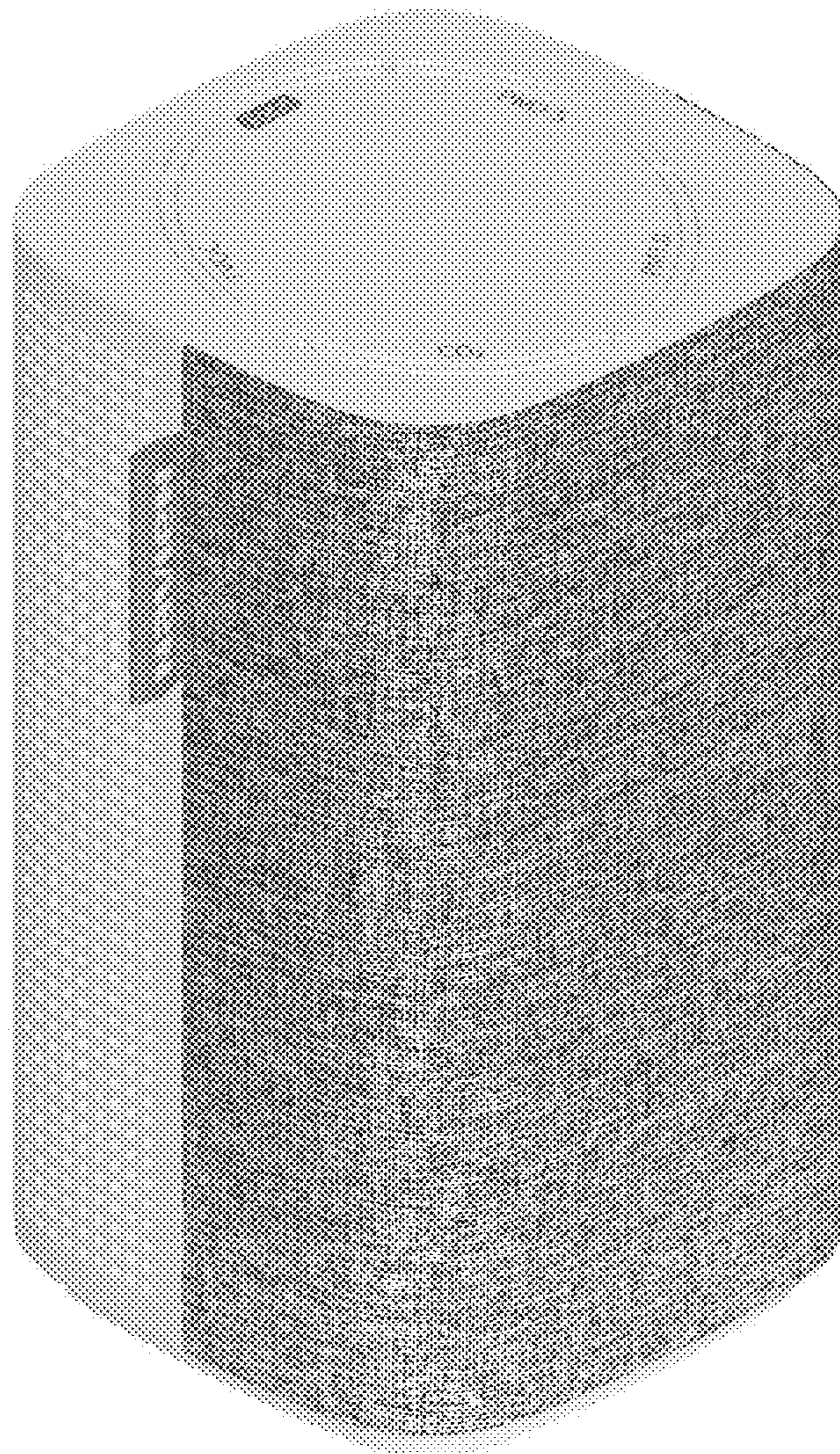


Fig 2

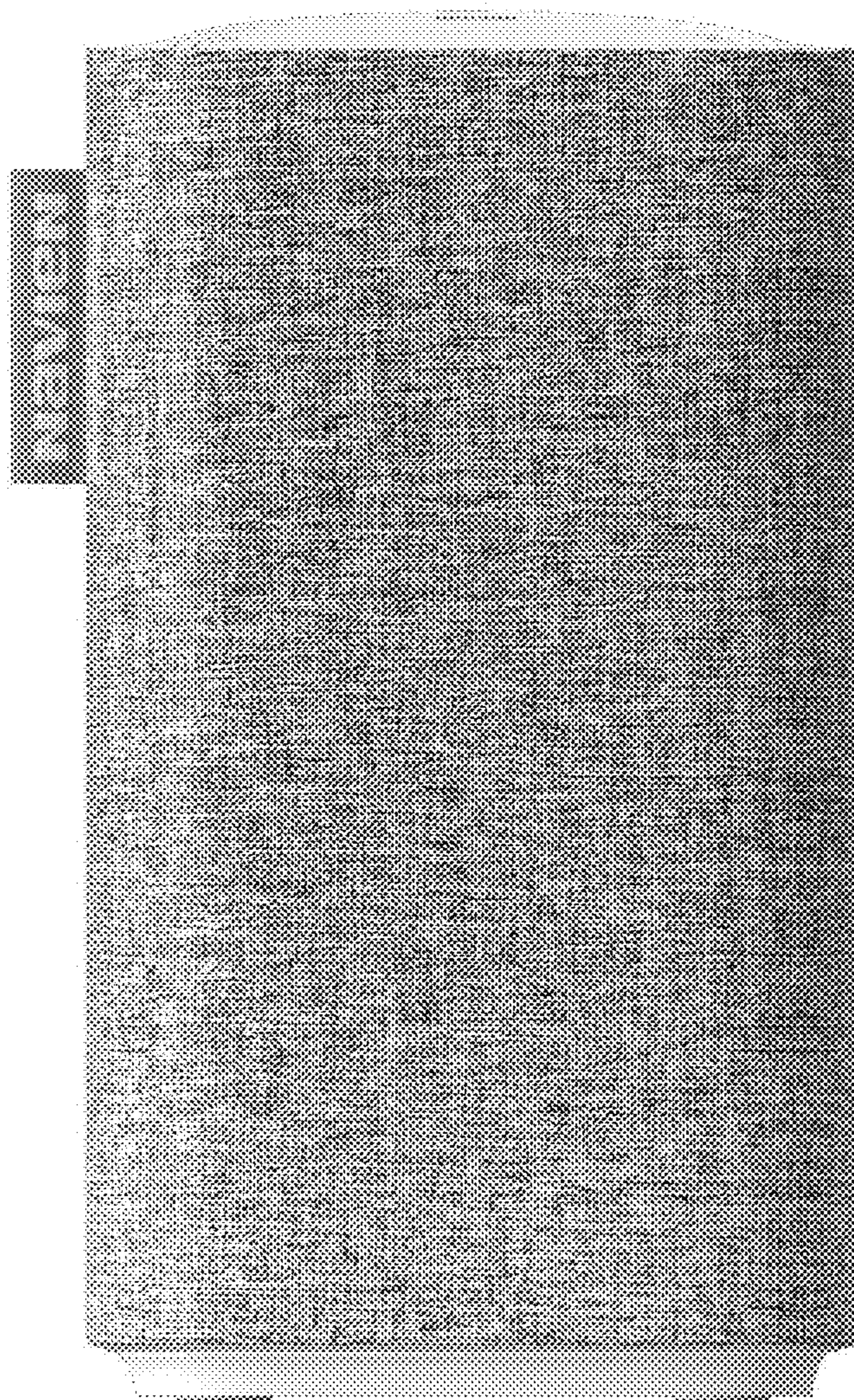


Fig 3

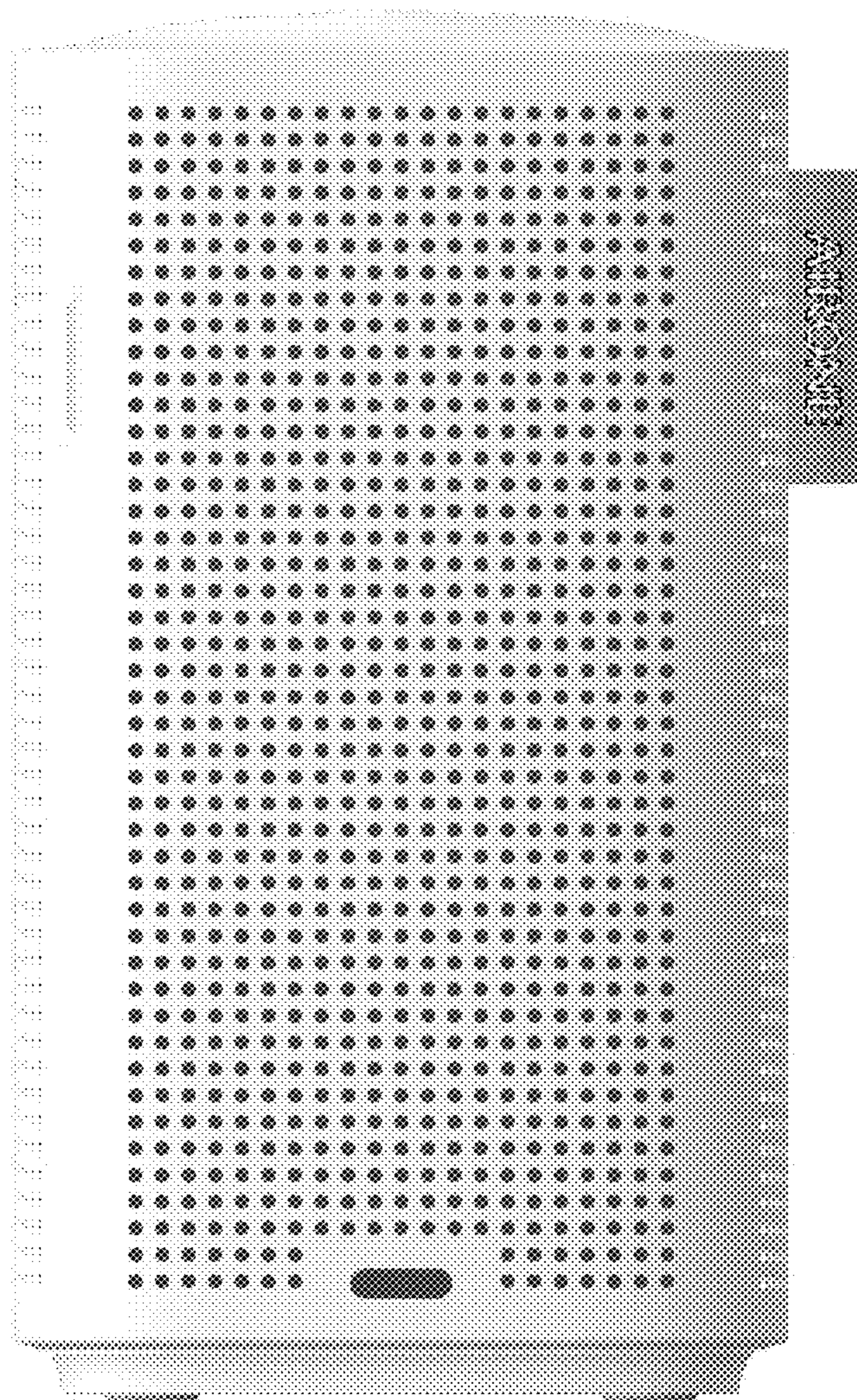


Fig 4

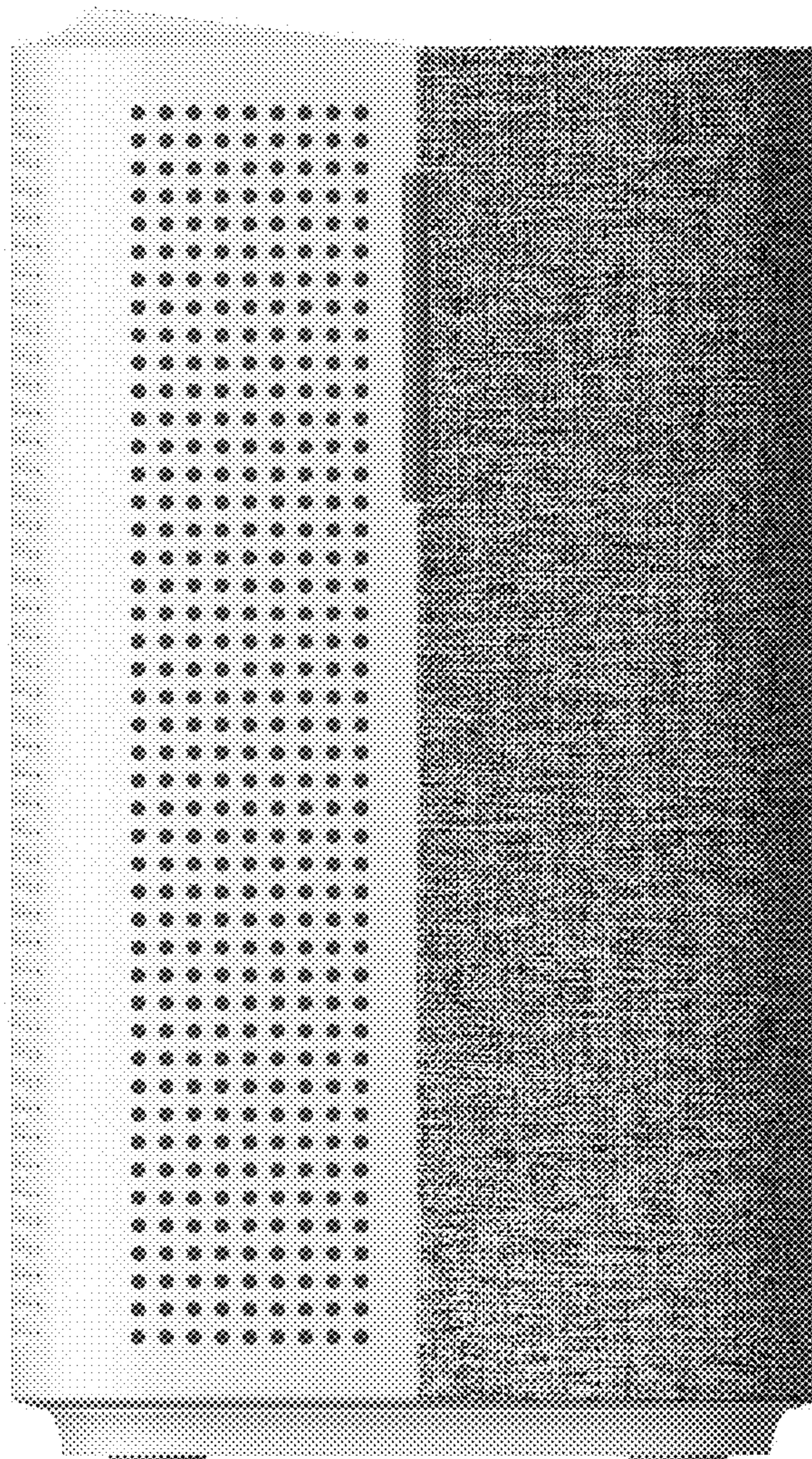


Fig 5

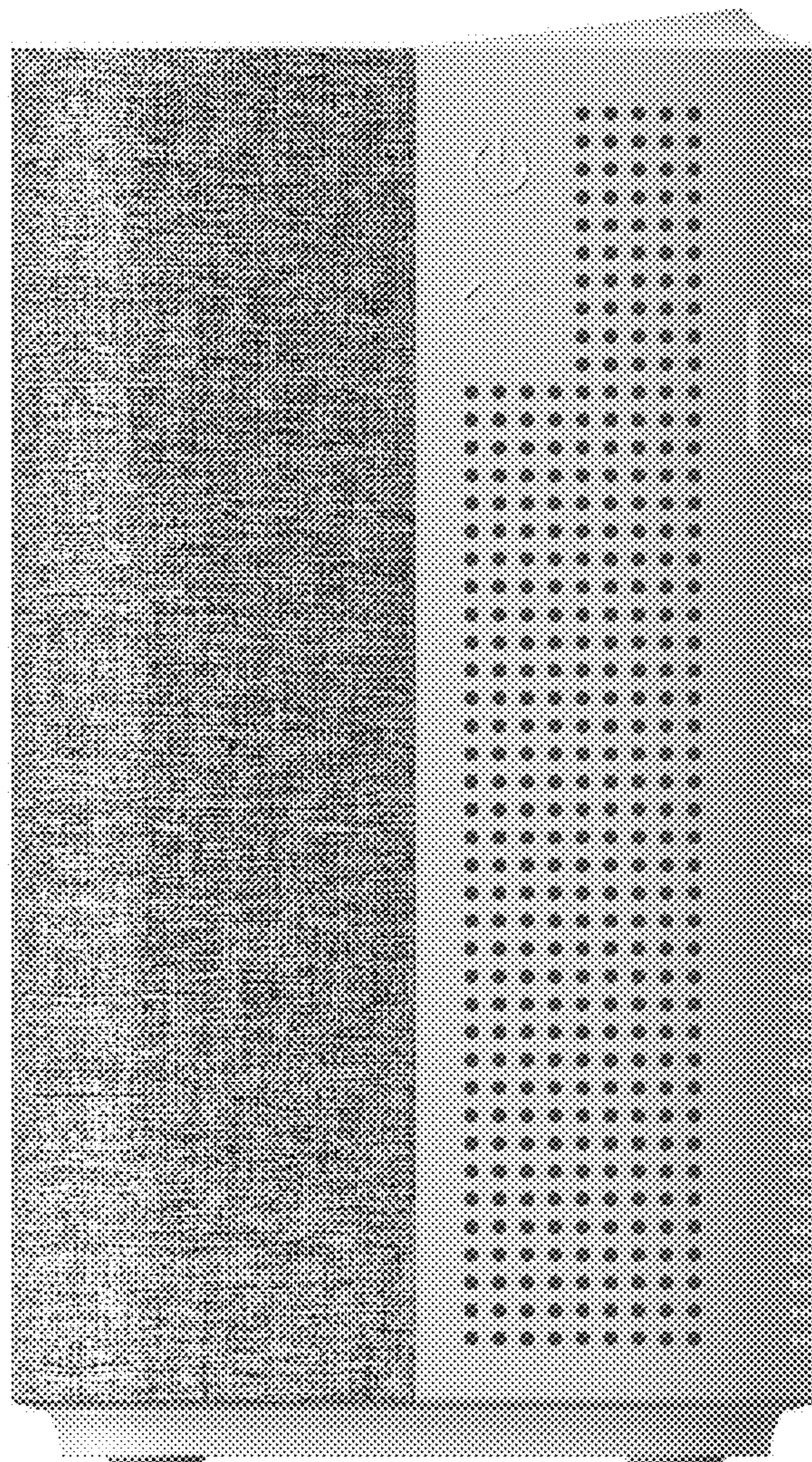


Fig 6

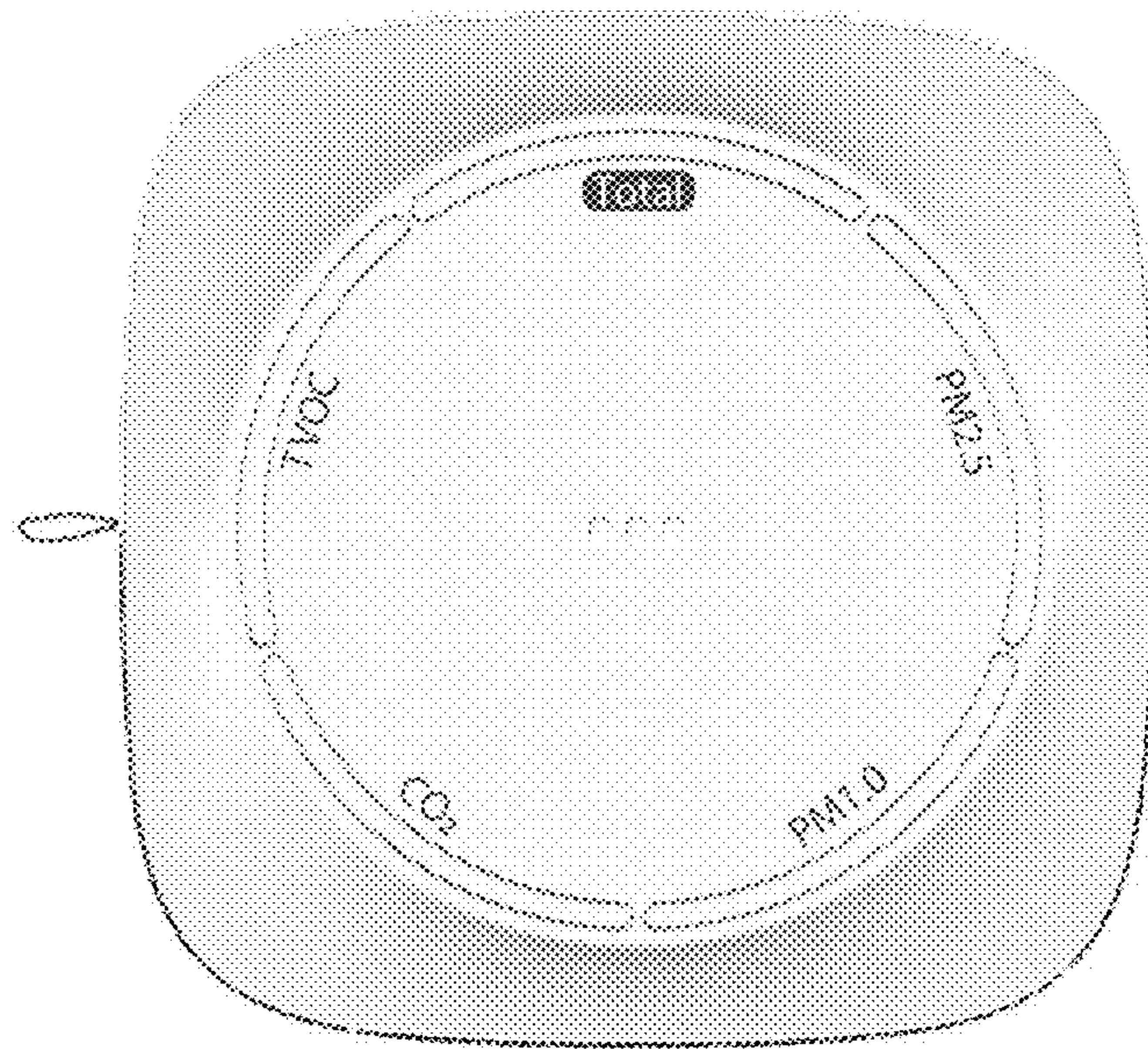


Fig 7

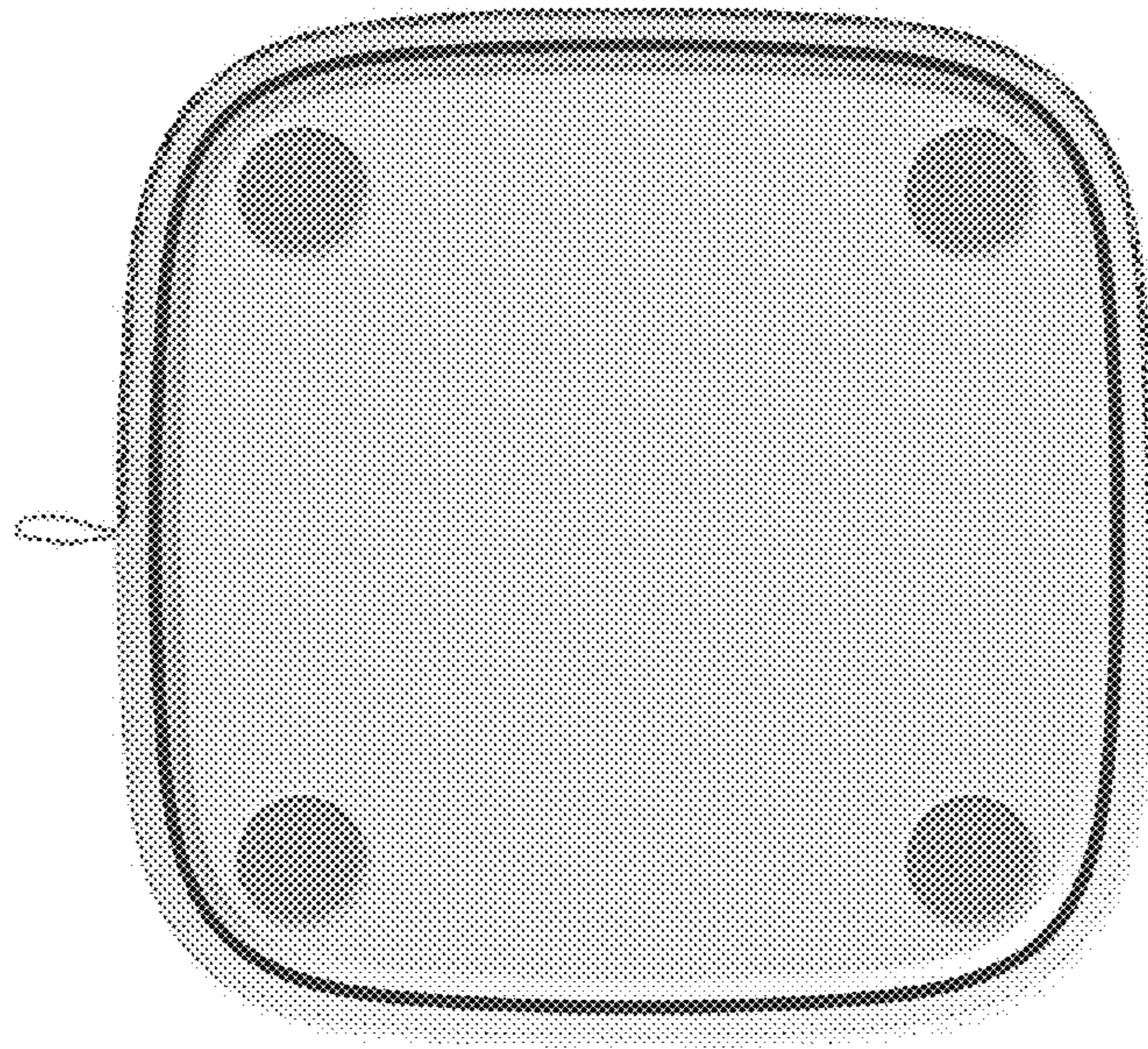


Fig 8

